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(71) Applicant: FUJIFILM ELECTRONIC MATERIALS
U.S.A., INC. [US/US]; 80 Circuit Drive, N. Kingstown, RI
02852 (US).

(72) Inventors: CHEN, Yuan; 3801 E Balsam Dr., Chan-
dler, AZ 85286 (US). ROMERO, Eduardo, Ramirez;
3101 Mustang Dr., Apt 712, Grapevine, TX 76051 (US).
HINZIE, Bryan; 5048 South Tatum Lane, Gilbert, AZ
85298 (US).

(74) Agent: ZHANG, Tony; Fish & Richardson P.C., P.O. Box
1022, New York, NY 55440-1022 (US).

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(54) Title: SYSTEMS AND METHODS FOR PURIFYING SOLVENTS

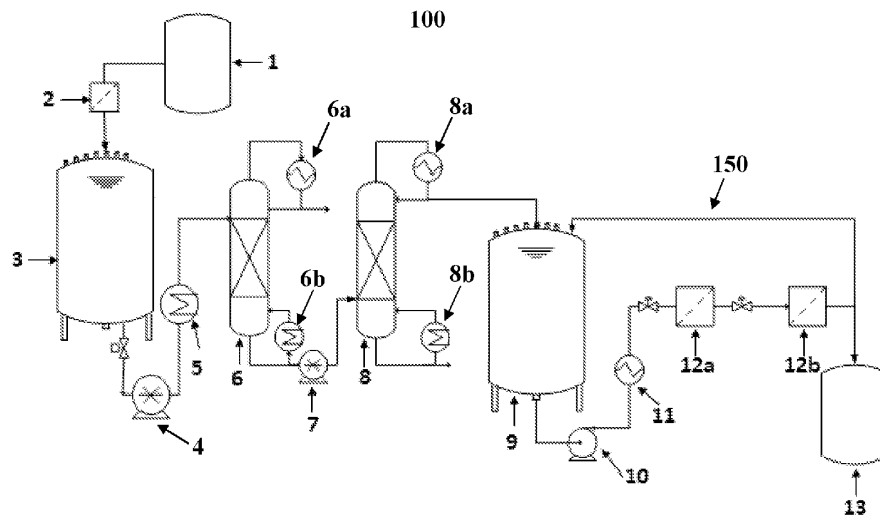


Figure 1

(57) Abstract: The present disclosure is directed to methods and systems of purifying solvents. The purified solvents can be used, e.g., as pre-wet liquids, solution developers, and cleaners in a multistep semiconductor manufacturing process.

[Continued on next page]

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